IN THE SPECIFICATION:

The specification as amended below with replacement paragraphs shows added text with <u>underlining</u> and deleted text with <u>strikethrough</u>.

Please REPLACE paragraph [0051] on pages 9-10 with the following amended paragraph:

[0051] As shown in FIG. 6B, the mask 110 is clamped and subjected to a tension in directions x and y. Here, the same tension can be applied in directions x and y. However, it is preferable that the four sides are subjected to optimal tensions +Px1 to +Px5, -Px1 to -Px5, +Py1 to +Py6, and -Py1 to -Py6, respectively. In this case, as shown in FIG. 7A, there is no deviation because the total pitches pitch Pt between two outermost lines 114 and 115 are is uniform. As shown in FIGS. 7B and 7C, the total pitch Pt may have a deviation (Ptma (ΔPt = Ptmax - Ptmin). As shown in FIGS. 7B through 7D, a line deviation (ΔX) may occur. Consequently, the application of different tensions for different sides of the mask can reduce the deviation of the total pitch and the line deviation.